



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

500.41080X00

3-18-03

11/14/2003
M. Rao

Applicants: MORIYA et al.
Serial No.: 10/043,099
Filed: January 14, 2002
For: SEMICONDUCTOR DEVICE AND ITS PRODUCTION
PROCESS
Group: 2814
Examiner: S. Rao

AMENDMENT

Assistant Commissioner
for Patents
Washington, D.C. 20231

March 10, 2003

Sir:

In response to the Office Action dated October 8, 2002, the period of response for which extension is requested by the attached Petition for Extension of Time, please amend the above-identified application as follows:

In the Claims:

Please cancel claims 1-11 without prejudice.

Please add new claims 17-24 as follows:

-- 17. A semiconductor device comprising:
a semiconductor substrate;
gate insulators formed on said substrate, and
gate electrodes formed on said gate insulators,

wherein said gate insulators are comprised of a material as a main component

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